

# Supplementary Material for Strain-tunable magnetic and electronic properties of $\text{CuCl}_3$ monolayer

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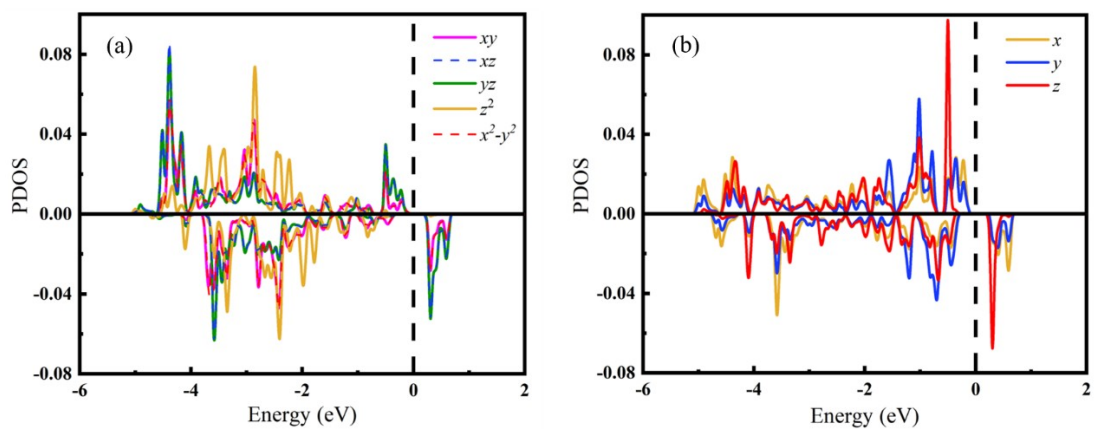


Fig. S1. (a) The *d* orbital PDOS of Cu atom and (b) the *p* orbital PDOS of Cl atom.

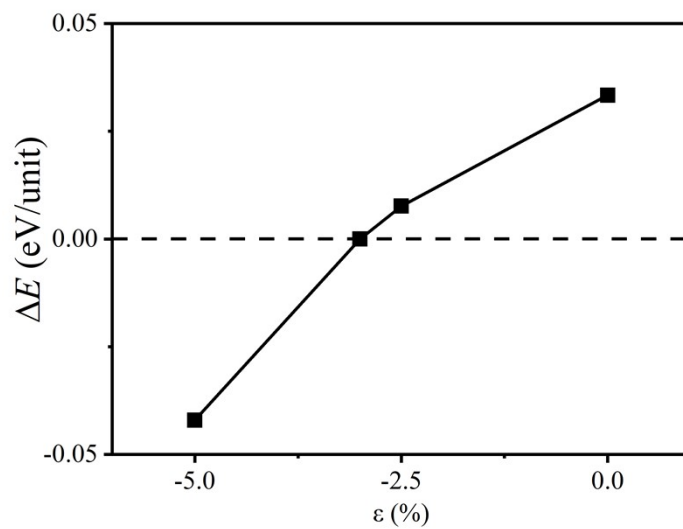


Fig. S2. Energy difference between FM and AFM  $\text{CuCl}_3$  monolayer as a function of the strain calculated by the LSDA.

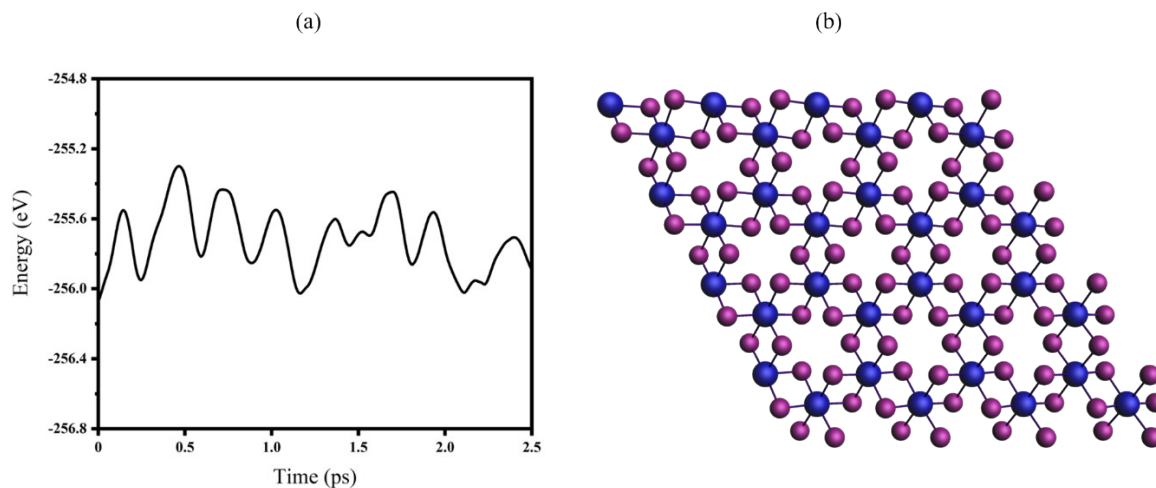


Fig. S3. (a) The potential energy fluctuation during the AIMD simulation at 300 K and (b) the top view of the atomic configuration of  $4 \times 4 \times 1$  CuCl<sub>3</sub> monolayer after 2.5 ps.